Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

Claim 1 (Currently amended): A process for synthesizing a the asymmetric synthesis of the chiral compound of the structure comprising the steps of

where Y is H, mono or multisubsubstituted electronwithdrawing group or electrondonating group, wherein Y can be located at *m* ,*o* ,or *p* -position of the benzene ring; P is hydgogen or an amino protecting group,

Rf is fluoro-containing alkyl,

R is trialkylsilyl, alkyl, cycloalkyl or aryl group,

R⁶ is hydrogen when R⁵ is hydroxy, also R⁵ and R⁶ can be HNCO of the structure or its enantiomer

where Y, P, R, Rf is the same as above;

Comprising the steps of:

(a) providing a mixture of mixing a chiral ligand (1R, 2R)-2-N, N- substituted-1(substituted -phenyl)-2-R³-substituted-2-aminoethanol or its enantiomer having a formula of, of the structure

$$Z \xrightarrow{\text{II}} \begin{array}{c} OH \\ R^3 \\ NR^1R^2 \\ Or \end{array} Z \xrightarrow{\text{II}} \begin{array}{c} OH \\ \frac{1}{2} \\ NR^1R^2 \end{array}$$

wherein R^1 , R^2 is <u>an</u> amino protecting group; [,] <u>and</u> R^3 is <u>an</u> alkyl,[;] alkyl-substituted with <u>an</u> alkyloxy or silyoxy, carboxylic group, carbalkoxy group, hydroxyl methyl, cycloalkyl, aryl, or CH_2OR^4 , wherein R^4 is being an oxygen protecting group[,]; Z is H, <u>a</u> mono_or multi-subsubstituted electron-withdrawing group or electron-donating group, <u>and wherein Z can be</u> located at m-,o-, or p-positon of the benzene ring; with a terminal alkyne and a Zn(II), Cu(II) or Cu(I) <u>salt salts</u> in the presence of an organic base in <u>an</u> aprotic solvent,

wherein the terminal alkyne is

R is a trialkylsilyl, alkyl, cycloalkyl, or aryl group the same as above,

(b) mixing with the mixture with a of step (a) of reactant having a formula of the structure

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or of the structure

wherein P is hydrogen or an amino protecting group, Rf is <u>a</u> fluoro-containing alkyl, Y is <u>H</u>, a mono- or multi-subsubstituted electron-withdrawing group or electron-donating group and located at *m*-, *o*-, or *p*-positon of the ring the same as above;

isolating and obtaining a chiral compound obtains the target addition product after normal isolation.

Claim 2 (Currently amended): The A process of claim 1, wherein the process is for the asymmetric synthesis of the chiral compound of the structure or its enantiomer

Comprising the steps of:

(a) providing a mixture of the chiral ligand (1R, 2R)-2-N, N- substituted-1-(substituted -phenyl)-2-R³-substituted-2-aminoethanol or its enantiomer is (1R, 2R)-2*N*,*N*-substitutedamino-1-(substituted-phenyl)-2-substituted-2-aminoethanol <u>having a</u> <u>formula of</u>, of the structure, or its enantiomer

with a terminal alkyne and a Zn(II) or Cu salts in the presence of an organic base in aprotic solvent, wherein the terminal alkyne is

(b) mixing with the mixture of step (a) of the reactant is of the structure

Claim 3 (Currently amended): The A process of claim 2, wherein the chiral ligand is (1R, 2R)-2-N,N-substitutedamino-1-(substituted-phenyl)-3-O-R⁴substituted-propane-1-ol or its enantiomer having a formula of 3 the structure

Claim 4 (Currently amended): The A process of claim 1, wherein the process is for the

asymmetric synthesis of the chiral compound of the structure or its enantiomer

Comprising the steps of:

(substituted- phenyl)- $2-R^3$ -substi- tuted-1-ethanol or its enantiomer <u>having a formula of</u>; of the structure;

with a terminal alkyne and a Zn(II) or Cu salts in the presence of an organic base in aprotic solvent, wherein the terminal alkyne is

(b) mixing with the mixture of step (a) of and the reactant is of the structure

Claim 5 (Currently amended): The A process of claim 1, wherein R¹ and R² is an

alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group can be being a phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, or $C_1 \sim C_3$ alkoxy[;], or R^1 , R^2 being can be $-(CH_2)_nX(CH_2)_{m^-}$, where X being can be CH_2 , O_2 or NH; n,m is an integer from 1 to 6[.];

P is hydrogen, <u>an</u> alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group <u>ean be being a phenyl, naphenyl, halo, nitro, hydroxy;</u>

 R^4 is <u>an</u> alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group <u>ean be being a phenyl</u>, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, $C_1 \sim C_3$ alkoxy or CN;

 $\underline{\text{the}} \text{ electron_withdrawing group is } \underline{a} \text{ halogen, NO}_2, \text{CF}_3, \text{CH}_3\text{SO}_2, \text{CH}_3\text{CH}_2\text{SO}_2 \text{ ,} \\ \text{PhCH}_2\text{OCO, or AcO[.]};}$

 $\underline{\text{the}} \text{ electron-donating group is } \underline{\text{an}} \text{ alkoxy, OH, } Me_2NCH_2CH_2O, Et_2NCH_2CH_2O, \\ NH_2, \underline{\text{or}} \ C_1 \sim C_4 \text{ alkyl.}$

Claim 6 (Currently amended): The A process of claim 1, wherein R^1 and R^2 is a $C_1 \sim C_{20}$ alkyl, $C_1 \sim C_{20}$ substituted alkyl, trialkylsilyl, benzyl, or substituted benzyl, the substituted group ean be being a phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxy alkyl, $C_1 \sim C_{20}$ alkyl, or $C_1 \sim C_3$ alkoxy[;], or R^1 , R^2 ean be being $C_1 \sim C_3$ alkoxy[;], where $C_1 \sim C_3$ alkoxy[;], or $C_1 \sim C_3$

n,m is an integer from 1 to 6;

 R^3 is <u>a</u> $C_1 \sim C_{20}$ alkyl[;], $C_1 \sim C_{20}$ alkyl substituted with <u>an</u> alkyloxy or silyoxy, carboxylic group, C_1 - C_{20} carbalkoxy group, hydroxyl methyl, $C_3 \sim C_{20}$ cycloalkyl, aryl, or

CH₂OR⁴, wherein R⁴ is being a $C_1 \sim C_{20}$ alkyl, $C_1 \sim C_{20}$ substituted alkyl, benzyl, or substituted benzyl, the substituted group can be being a phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, $C_1 \sim C_3$ alkoxy, or CN;

Z is H, F, Cl, Br, I, CH₃SO₂, OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, PhCH₂OCO, *t*-Bu, *i*-Pr, NH₂, or NO₂:

P is hydrogen, <u>a</u> $C_1 \sim C_{20}$ alkyl, $C_1 \sim C_{20}$ substituted alkyl, benzyl, trialkylsilyl or substituted benzyl, the substituted group <u>ean be being a phenyl</u>, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, $C_1 \sim C_3$ alkoxy, or CN;

Y is H, F, Cl, Br, I, CH₃SO₂, OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, PhCH₂OCO, *t*-Bu, *i*-Pr, NH₂, or NO₂;

Rf is <u>a</u> $C_1 \sim C_{20}$ fluoro-containing alkyl;

R is <u>a</u> trialkylsilyl, $C_1 \sim C_{20}$ alkyl[.], $C_3 \sim C_{20}$ cycloalkyl, or aryl group[;].

Claim 7 (Currently amended): The A process of claim 1, wherein R^1 and R^2 is a $C_1 \sim C_4$ alkyl, tri-phenylmethyl, t-butyldimethylsilyl, benzyl unsubstituted or substituted with C_1 - C_4 alkyl[;], para-methoxy benzyl[;], para-nitrobenzyl[;], para-chlorobenzyl[;], 2, 4-dichlorobenzyl[;], or 2, 4-dimethoxybenzyl[;], or R^1 , R^2 can be being -(CH₂)₂O(CH₂)₂-, -(CH₂)₅-, or -(CH₂)₆-;

 R^3 is <u>a</u> $C_1 \sim C_4$ alkyl, $C_1 \sim C_4$ alkyl substituted with alkyloxy or silyoxy, carboxylic group, $C_1 \sim C_4$ carbalkoxy group, hydroxyl methyl, $C_3 \sim C_6$ cycloalkyl, aryl or CH_2OR^4 , wherein R^4 being <u>a</u> is $C_1 \sim C_4$ alkyl, tri-phenyl methyl, *t*-butyl- dimethylsilyl, benzyl unsubstituted or substituted with $C_1 \sim C_4$ alkyl, *para*-methoxy benzyl, *para*-nitrobenzyl,

para-chlorobenzyl, 2, 4-dichlorobenzyl, 2, 4- dimethoxybenzyl, or trialkylsilyl groups;

Z is H, F, Cl, Br, I, CH₃SO₂, OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, PhCH₂OCO, *t*-Bu, *i*-Pr, NH₂, or NO₂;

P is hydrogen, <u>a</u> $C_1 \sim C_4$ alkyl, tri-phenylmethyl, *t*-butyldi- methylsilyl, benzyl unsubstituted or substituted with $C_1 \sim C_4$ alkyl; *para*-methoxy benzyl, *para*-nitrobenzyl, *para*-chlorobenzyl, 2,4-dichlorobenzyl, <u>or</u> 2, 4-dimethoxy- benzyl;

Y is H, Cl, Br, CH₃SO₂, CH₃CH₂SO₂, NO₂, or F;

Rf is \underline{a} C₁~C₄ fluoro-containing alkyl;

R is <u>a</u> $C_1 \sim C_4$ alkyl, $C_3 \sim C_6$ cycloalkyl, or aryl group, wherin aryl is <u>being a</u> phenyl, naphenyl, furan, thiophene, <u>or</u> pyrrole;

Halogen halogen or halo is a fluoro, chloro, bromo, or and iodo.

Claim 8 (Currently amended): The A process of claim 1, wherein the stoichiometric ratios are about 0.1-3:0.1-3:1-4:1 of ligand: Zinc salt: the organic base: substrate ketone or ketimine.

Claim 9 (Currently amended): The A process of claim 1, wherein the Zine salt is selected from ZnCl₂, ZnBr₂, ZnF₂, ZnI₂, Zn(OTf)₂, CuCl₂, CuBr₂, Cu(OTf)₂, CuCl, CuBr, or Cu(OTf).

Claim 10 (Currently amended): The A process of claim 1, wherein the organic base is selected from $MeN(iPr)_2$, $HNEt_2$, $N(iPr)_3$, pyridine, NEt_3 , piperidine, $EtN(iPr)_2$, or Bu_3N .

Claim 11 (Currently amended): The A process of claim 1, wherein the reaction temperature is 0-100°C

Claim 12 (Currently amended): The A process of claim 11 4, wherein the reaction temperature is 0-50°C.

Claim 13 (Currently amended): The A process of claim 1, wherein the <u>aprotic reaction</u> solvent is selected from THF, dioxane, Et₂O, benzene, <u>a</u> mono or multi-alkylsubstituted-benzene, DME, toluene, n-hexane, CH₂Cl₂ and , cyclohexane, or <u>a</u> mixture thereof. One preferred solvent is toluene.

Claim 14 (Currently amended): The A process of claim 1, wherein further comprising the step of

quenching the <u>mixture</u> reaction by adding a proton source to give the <u>chiral</u> desired compound.

Claim 15 (Currently amended): The A process of claim 1, comprising the steps of wherein it is for the asymmetric synthesis of the chiral compound of the structure

or of the structure

Comprising the steps of:

(a) providing a mixture of mixing 0.1~3 molar equivalent of (1R,2R)-2-N,N-substitutedamino-1-(4-Z-substituted-phenyl)-3-O-R⁴-substituted propane-1-ol having a formula of [,] of the structure

with 0.1~3 molar equivalent of cyclopropylacetylene, and 0.1~3 molar equivalent of Zn(II), Cu(I) or Cu(II) salts, and 1~4 molar equivalent of an organic base in organic solvent;

(b) mixing with the mixture of step (a) with 1.0 molar equivalent of a reactant having a formular of of the structure

or of the structure

and maintaining the resulting reaction mixture at a temperature of between about 0-50°C for 1-20 hrs[.];

- (c) quenching by adding a proton source;
- (d) to give the desired obtaining the chiral compound.

Claim 16 (Currently amended): The A compound of the structure or its enantiomer having a formula of

wherein R^1 , R^2 is \underline{an} amino protecting group[,];

and R⁴ is an oxygen protecting group;

Z is $\underline{NO_2}$, $\underline{CH_3SO_2}$, or $\underline{CH_3CH_2SO_3}$ mono or multisubstituted electron—withdrawing group or electron-donating group;

and when Z is NO_2 at 4-postion of the phenyl, R^1 is N=0, R^2 is $COCH_3$, R^4 is an only alkyl, substituted alkyl, benzyl, substituted benzyl, or trialkylsilyl;

and when Z is NO_2 at 4-postion of the phenyl, R^1 , R^2 is CH_3 , the ligand is only (1R, 2R)-2-N,N-dimethylamino-1-(4- nitrophenyl)-3-O- R^4 -1-propanol[;]

and when Z is OCH₃ at 4-postion of the phenyl, R⁴, R² is CH₃, R⁴ is an only alkyl,

substituted alkyl, benzyl ,substituted benzyl; said substituted group is phenyl , naphthyl, halogen , NO_2 , hydroxyl, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, $C_1 \sim C_3$ alkoxy, or CN_2 .

Claim 17 (Currently amended): The compound of claim 16 having a formula of , of the structure or its enantiomer

Claim 18 (Currently amended): The compound of claim 16, of the structure having a formula of or its enantiomer

Claim 19 (Currently amended): The compound of claim 16, wherein R^1 and R^2 is an alkyl, substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group ean be being a phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, or $C_1 \sim C_3$ alkoxy[;], or R^1 , R^2 ean be being -(CH₂)_nX(CH₂)_m-, where X ean be being a CH₂, O₂ or NH;

n,m is an integer from 1 to 6;

 R^4 is <u>an</u> alkyl, substituted alkyl, benzyl, or substituted benzyl, the substituted group <u>ean be being a phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxy alkyl, alkyl, $C_1 \sim C_3$ alkoxy, or CN;</u>

electronwithdrawing groupis halogen, <u>Z is NO₂</u>, CF3,CH₃SO₂, or CH₃CH₂SO_{2[,]} PhCH₂OCO, or AcO:

electron donating group is $C_1 \sim C_3$ alkoxy, OH, $Me_2NCH_2CH_2O$, $Et_2NCH_2CH_2O$, NH_2 , $C_4 \sim C_4$ alkyl;

and when Z is NO_2 at 4-postion of the phenyl, R^1 is N=0, R^2 is $COCH_3$, R^4 is only alkyl, substituted alkyl, benzyl ,substituted benzyl, or trialkylsilyl;

and when Z is NO₂ at 4-postion of the phenyl, R^1 , R^2 is CH₃, the ligand is only (1R, 2R)-2-N,N-dimethyl-1-(4- nitrophenyl)-3-O- R^4 -1-propanol[;]

and when Z is OCH₃ at 4-postion of the phenyl, R⁴, R² is CH₃, R⁴ is only alkyl, substituted alkyl, benzyl, substituted benzyl.

Claim 20 (Currently amended): The compound of according to claim 16, wherein R^1 and R^2 is a $C_1 \sim C_{20}$ alkyl, $C_1 \sim C_{20}$ substituted alkyl, trialkylsilyl, benzyl, or substituted benzyl, the substituted group of alkyl or benzyl ean be being a phenyl, naphenyl, halo, nitro, hydroxy, $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, $C_1 \sim C_3$ alkoxy, or CN[;], or R^1 , R^2 ean be being $-(CH_2)_nX(CH_2)_{m^2}$, where X can be being CH_2 , X or X

n,m is an integer from 1 to 6;

 R^4 is <u>a</u> $C_1 \sim C_{20}$ alkyl, $C_1 \sim C_{20}$ substituted alkyl, benzyl, trialkylsilyl, or substituted benzyl, the substituted group <u>ean be being a phenyl</u>, naphenyl, halo, nitro, hydroxy,

 $C_1 \sim C_3$ hydroxyalkyl, $C_1 \sim C_4$ alkyl, $C_1 \sim C_3$ alkoxy or CN;

Z is H, F, Cl, Br, I, CH₃SO₂ OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, PhCH₂OCO, t-Bu, i-Pr, NH₂, or NO₂;

and when Z is NO_2 at 4-postion of the phenyl, R^1 is N=0, R^2 is $COCH_3$, R^4 is only an alkyl, substituted alkyl, benzyl, substituted benzyl, or trialkylsilyloxy;

and when Z is NO₂ at 4-postion of the phenyl, R^1 , R^2 is CH₃, the ligand is only (1R, 2R)-2-N,N-dimethyl- amino-1-(4- nitrophenyl)-3-O- R^4 -propane-1-ol[;]

and when Z is OCH₃ at 4-postion of the phenyl, R^4 , R^2 is CH₃, R^4 is only alkyl, substituted alkyl, benzyl, substituted benzyl; said substituted group is phenyl, naphthyl, halogen, NO₂, hydroxyl, C₁~C₃ hydroxyalkyl, C₁~C₄ alkyl, C₁~C₃ alkoxy, or CN;

Claim 21 (Currently amended): The compound of according to claim 16, wherein R^1 and R^2 is a $C_1 \sim C_4$ alkyl, tri-phenyl methyl, t-butyldimethylsilyl, benzyl unsubstituted or substituted with $C_1 \sim C_4$ alkyl[;], para-methoxy benzyl[;], para-nitrobenzyl[;], para-chlorobenzyl[;], 2, 4-dichlorobenzyl[;], 2, 4-dimethoxybenzyl;

 R^4 is <u>a</u> $C_1 \sim C_4$ alkyl, tri-phenyl methyl, *t*-butyldimethylsilyl, benzyl unsubstituted or substituted with $C_1 \sim C_4$ alkyl[;], *para*-methoxy benzyl[;], *para*-nitrobenzyl[;], *para*-chlo-robenzyl[;], 2, 4-dichlorobenzyl[;], or 2, 4-dimethoxybenzyl;

Z is H, F, Cl, Br, I, CH₃SO₂ OH, PhCH₂O, AcO, MeO, EtO, Me₂NCH₂CH₂O, Et₂NCH₂CH₂O, PhCH₂OCO, t-Bu, i-Pr, NH₂, or NO₂;

and when Z is NO_2 at 4-postion of the phenyl, R^1 is N=0, R^2 is $COCH_3$, R^4 is only an alkyl, substituted alkyl, benzyl ,substituted benzyl, or trialkylsilyl;

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and when Z is NO_2 at 4-postion of the phenyl, R^1 , R^2 is CH_3 , the ligand is only (1R, 2R)-2-N,N-dimethyl-amino-1-(4-nitrophenyl)-3-O- R^4 -propane-1-ol[;] and when Z is OCH_3 at 4-postion of the phenyl, R^4 , R^2 -is CH_3 , R^4 -is only alkyl, substituted alkyl, benzyl, substituted benzyl.